Forward Electron Truthmatching

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Lukas Bayer Hamburg



HELMHOLTZ

Control Plot vs SF Fit Plot

observed differences



DESY.

Control Plot vs SF Fit Plot

differences in selection

Criteria \ Inputs for:	SF Fits	Control Plots
central electron ID	tight + isolation (only tight is sys variation)	tight
forward electron truthmatching	required	not required

- cenID difference is okay
 - \circ eID_SFs are determined with tag-and-probe \rightarrow tight cut on tag required
 - difference of including isolation covered in sys variations
- truthmatching difference is problematic
 - SF fits treat non-truthmatched MC events as background
 - \rightarrow calculates SFs **only** for truthmatched events
 - analysis scans / control plots treat non-truthmatched MC events as signal
 - \rightarrow SFs are applied to **all** MC events

How large is the effect of the trithmatching cut?



Control Plots

(applied SF have been determined with truthmatching)



MJ Estimation

with Fake Factor Method



MJ Estimation

with Fake Factor Method

control region

MJ = data - signalMC



to include fTM events in MJ estimate: ratio of ID/nL needs to be the same for MJ and fTM \rightarrow LH distribution needs to be the same \rightarrow SPOILER: that's not the case



Page 8

Electron ID LH

Distribution in MC



lepton type



lepton origin



FSR Photons

if (!(fwdType == IsoElectron && (fwdOrigin==ZBoson || fwdOrigin==ZorHeavyBoson)) &&
!(fwdType == IsoPhoton && (fwdOrigin==ZBoson || fwdOrigin==ZorHeavyBoson)) &&
!(fwdType == BkgElectron && (fwdOriginBkg==ZBoson|| fwdOriginBkg==FSRPhot))) pass = false;

does not exist in ntuples for 13 TeV !!!



include fwdType == NonIsoPhoton && fwdOriginBgk == FSRPhot into truthmatching



expect only (mostly MJ) background in that region

